

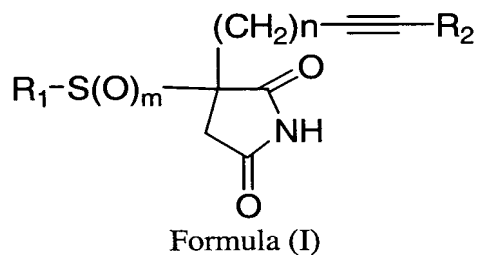
Amendments to the Claims:

This listing of claims will replace all prior versions, and listings, of claims in the application:

Listing of claims:

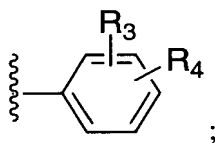
1-19 (canceled).

20. (Original) A process for the preparation of a compound of Formula (I).

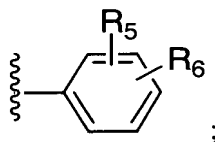


wherein:

R<sub>1</sub> is a moiety



R<sub>2</sub> is a moiety



n is an integer of 1 and 3-9;

m is an integer of 0 or 2;

R<sub>3</sub> and R<sub>4</sub> are independently selected from the group consisting of hydrogen, alkyl of 1 to 10 carbon atoms, alkoxy of 1 to 10 carbon atoms, halogen, nitro,

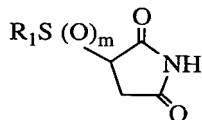
trifluoromethoxy, phenoxy optionally mono or di substituted, and benzyloxy optionally mono or di substituted;

$R_5$ , and  $R_6$ , are independently selected from the group consisting of hydrogen, alkyl of 1 to 10 carbon atoms, halogen, nitro, phenyl optionally mono or di-substituted, phenoxy optionally mono or di-substituted, trifluoromethyl, trifluoromethoxy, and methanesulphonyl.

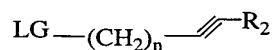
or a pharmaceutically acceptable salt thereof,

which comprises

reacting a compound of the formula



with an alkyne of the formula



wherein LG is a leaving group

in the presence of a base to give a compound of Formula (I)

or a pharmaceutically acceptable salt thereof.

21. (Original) The process according to Claim 20 wherein the base is selected from alkali metal hydrides, alkali metal alkyls and alkali metal amide bases.

22. (Original) The process according to Claim 21 where the alkali metal hydride is sodium hydride.
23. (Original) The process according to Claim 21 wherein the alkali metal alkyl is butyl lithium.
24. (Original) The process according to Claim 21 wherein the alkali metal amide base is selected from lithium diisopropylamide and lithium bis(trimethylsilyl)amide.
25. (Original) The process according to Claim 20 wherein the leaving group is p-toluenesulfonyloxy, iodo or bromo.